

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1481	(Ru or Ruthenium) near8 ((bottom or lower) near4 (plate electrode))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/10/25 13:15
L2	4	1 same precursor same (heat or chuck or thermal or heated or heating or thermally) same (substrate or wafer or holder or carrier)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/10/25 13:15
L4	171	1 and capacitor and precursor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/10/25 13:15
L5	66	4 and ((@ad<"20010131") or (@rlad<"20010131"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:12
L6	66	5 and (heat\$4 or temperature)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:12
L7	298522	(heat\$4 or anneal\$4) near8 (substrate or wafer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:12
L8	436	1 and 7	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:12
L9	223	8 and ((@ad<"20010131") or (@rlad<"20010131"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:13
L10	176	9 not 6	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:48

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L11	6	10 and pre-heat\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:54
L12	80	organoruthenium or (organo near ruthenium) same precursor same oxidation	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:56
L13	31608	(pre-heat\$4 or stabilize or stabilized or stabilizing) near8 (substrate or wafer or carrier or holder)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:56
L14	0	12 and 13	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 15:56
L15	13	12 and capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 16:11
L16	47508	Micron.as. or Renesas.as.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 16:12
L17	5	16 and organoruthenium and capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/10/25 16:12